

EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|----------|------------------|---------|------------------|
| L1 | 199 | ((substrate or wafer) and chamber and (reaction adj product\$1)).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:40 |
| L2 | 126 | ((substrate or wafer) same chamber and (reaction adj product\$1)).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:27 |
| L3 | 68 | ((substrate or wafer) same chamber same (reaction adj product\$1)).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:27 |
| L4 | 139 | 1 and (remov\$4 or reduc\$5 or clean\$\$).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:28 |
| L5 | 61 | 1 and ((remov\$4 or reduc\$5 or clean\$\$) same (reaction adj product\$1)).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:31 |
| L6 | 44 | 1 and ((remov\$4 or reduc\$5 or clean\$\$) same (reaction adj product\$1) same chamber).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:31 |
| L7 | 22 | ((semiconductor) same chamber and chamber same (reaction adj product\$1)).clm. | US-PGPUB | OR | OFF | 2006/06/06 09:41 |